



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Suguru TSUCHIYA

Group Art Unit : 2626

Appl. No. : 09/905,073

Examiner : M. A. V. NGUYEN

Filed : July 16, 2001

Confirmation No. : 5081

For : FACSIMILE APPARATUS AND REPEATER

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop AMENDMENT
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir :

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98 and supplemental to the Information Disclosure Statement that was filed on October 24, 2001, and with the concurrently filing of a Request for Continued Examination ("RCE"), the examiner's attention is respectfully directed to two Notices of Reasons for Rejection that were mailed, respectively, on October 22, 2002 and August 12, 2003, with respect to patent family member Japanese Patent Application No. 2000-215823, together with English language translations of the same, in which the following documents were cited:

1. Japanese Laid-Open Patent Publication No. H11-168614, together with an English language abstract and an English language translation of a relevant portion thereof.

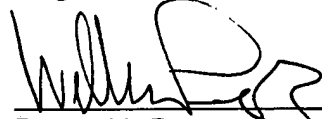
2. Japanese Laid-Open Patent Publication No. 2000-22862, together with an English language abstract and an English language translation of a relevant portion thereof.
3. Japanese Laid-Open Patent Publication No. H10-126551, together with an English language abstract and an English language translation of a relevant portion thereof.
4. Japanese Laid-Open Patent Publication No. H01-164147, together with an English language abstract of the same.
5. Japanese Laid-Open Patent Publication No. H10-126549, together with an English language abstract of the same.
6. Japanese Laid-Open Patent Publication No. H07-007589, together with an English language abstract of the same.

The relevance of these documents, as ascertained by the Japanese Examiner are set forth in the Notices of Reasons for Rejection.

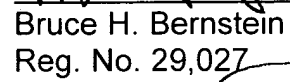
Applicant respectfully requests that the Examiner consider the above material and cite the same. Copies of the above-noted documents are attached hereto and listed on the attached PTO-1449 Form. Copies of the Notices of Reasons for Rejection and their English language translations are also attached hereto. The Examiner is requested to initial the appropriate spaces on the attached Form and to return a copy of the completed Form to Applicant with the next official communication in the present application.

Should the Examiner have any questions, the Examiner is invited to
contact the undersigned at the below-listed telephone number.

Respectfully Submitted,
Suguru TSUCHIYA



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December 29, 2005
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FORM PTO-1449

U.S. Department of Commerce
Patent and Trademark OfficeAtty. Docket No.
P20746Application No.
09-905,073

INFORMATION DISCLOSURE STATEMENT
BY APPLICANT
(Use several sheets if necessary)

Applicant
Suguru TSUCHIYAFiling Date
July 16, 2001Group
2626

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
	11	- 1 6 8 6 1 4	06/22/99	JAPAN			X
	2000	- 2 2 8 6 2	01-21/00	JAPAN			X
	10	- 1 2 6 5 5 1	05/15/98	JAPAN			X
	01	- 1 6 4 1 4 7	06/28/89	JAPAN			
	10	- 1 2 6 5 4 9	05/15/98	JAPAN			
	07	- 0 0 7 5 8 9	01/10/95	JAPAN			

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

1	English language Abstract of JP 11-168614.
2	English language Abstract of JP 2000-22862.
3	English language Abstract of JP 10-126551.
4	English language Abstract of JP 01-164147.
5	English language Abstract of JP 10-126549.
6	English language Abstract of JP 07-007589.

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.